

**INFORMATION DISCLOSURE
CITATION**

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APPLICANT

JAHROMI et al



(Use several sheets if necessary)

FILING DATE

TC/A.U.

July 3, 2006

Unassigned

U.S. PATENT DOCUMENTS

FOREIGN PATENT DOCUMENTS

DOCUMENT		DATE	country	CLASS	subclass	TRANSLATION YES	NO
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OTHER DOCUMENTS (including Author, Title, Date, Pertinent pages, etc.)

European Search Report	5/2004
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M ROTHSCHILD et al; "Fluorine – an enabler in advanced photolithography"; Journal of Fluorine Chemistry; vol. 122; no. 1; July 1 2003; pages 3-10	

/Brittany Raymond/

Date Considered

03/27/2008

Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include reference to this page in the Remarks section of the application.

ALL PREFERENCES CONSIDERED EXCEPT WHERE LINED THROUGH /P.P/

Form PTO-FB-AB20 (Also PTO/SB/08A)